

# STIC Search Report

# STIC Database Tracking Number: 224206

TO: Sanza McClendon Location: REM 10D51

Art Unit: 1711 May 8, 2007

Case Serial Number: 10/671438

From: Kendra Banks Location: EIC 1700 REMSEN 4B28

Phone: 571/272-2516

Kendra.Banks@uspto.gov

# Search Notes

No Cases Reported

US 6,365,644



## Banks, Kendra

From:

SANZA MCCLENDON [sanza.mcclendon@uspto.gov]

Sent:

Saturday, May 05, 2007 3:31 PM

To:

STIC-EIC1700

Subject:

Database Search Request, Serial Number: 10/671,438

Requester:

SANZA MCCLENDON (P/1711)

Art Unit:

GROUP ART UNIT 1711

Employee Number:

75688

Office Location:

REM 10D51

Phone Number:

(571)272-1074

Mailbox Number:

10D79

Case serial number:

10/671,438

Class / Subclass(es):

522/168

Earliest Priority Filing Date:

12/12/1997

Format preferred for results:

Paper

Search Topic Information:

Can you please do a litigation search on 6,365,644. Thank you

Special Instructions and Other Comments:

#### Current session 08/05/2007

(C) QUESTEL 1994

QUESTEL.ORBIT (TM) 1998 08/05/07 17\*40\*49

Last connection: 04/05/07 20\*43\*02

WELCOME to QUESTEL.ORBIT- Your Guide to INTELLECTUAL PROPERTY www.questel.orbit.com -Gateway, documentation & IP resource -Times of operation of Questel.Orbit service, see INFO HOURS -FamPat:key full text content added; see details on website -\*Important Notice regarding INPADOC: after September 30th, all INPADOC searches will be directed to the PlusPat file. Please see Questel.Orbit website for additional information -DWPI/DWPX/WPAM reloaded. Source data now available in the DWPIMV Member View file. See DWPI/DWPX & WPAM Fact Sheets ..FILE / ..INFO / ..GUIDE

### Query/Command : FILE PLUSPAT

QUESTEL - Time in minutes : 0,63

The cost estimation below is based on Questel's

standard price list

Estimated cost: 0.71 USD

Cost estimated for the last database search: 0.71 USD

Estimated total session cost : 0.71 USD

Selected file: PLUSPAT

PLUSPAT - (c) Questel-Orbit, All Rights Reserved.

Comprehensive Worldwide Patents database

Individual records for each Country or Patent Office

Coverage: 77 patenting authorities; start dates vary from 1800 forward For PlusPat Fact Sheet, Pricing and FAQ, see the Questel.Orbit website Citations and FI/F-term classification available for Japanese documents Last update of file: 2007/05/04 (YYYY/MM/DD) 2007-18/UP (last update)

Search statement 1

Query/Command: US6365644/PN

#### \*\* SS 1: Results 1

Search statement 2

#### Query/Command: PRT FULL NONSTOP LEGALALL

1/1 PLUSPAT - ©QUESTEL-ORBIT - image

PN - US6365644 B1 20020402 [US6365644]

TI - (B1) Photo-curable resin composition used for photo-fabrication of three-dimensional object

PA - (B1) JSR CORP (JP); JAPAN FINE COATINGS CO LTD (JP); DSM NV (NL)

PA0 - DSM N.V., Heerlen [NL]
JSR Corporation, Tokyo [JP]
Japan Fine Coatings Company, Ltd., Tokyo [JP]

IN - (B1) WATANABE TSUYOSHI (JP); TAKEUCHI AKIRA (JP); UKACHI TAKASHI (JP); YAMAMURA TETSUYA (JP)

**AP** - US39403199 19990913 [1999US-0394031]

**FD** - Cont. of US989407 19971212 [1997US-0989407] Continuation of: US5981616

PR - US39403199 19990913 [1999US-0394031] JP35289396 19961213 [1996JP-0352893] US98940797 19971212 [1997US-0989407]

IC - (B1) C08F-002/46

ICAA - G03F-007/00 [2006-01 A - I R M EP]; G03F-007/038 [2006-01 A - I R M EP]; G03F-007/075 [2006-01 A - I R M EP]

ICCA - G03F-007/00 [2006 C - I R M EP]; G03F-007/038 [2006 C - I R M EP]; G03F-007/075 [2006 C - I R M EP]

EC - G03F-007/00S G03F-007/038 G03F-007/075F G03F-007/075M

PCL - ORIGINAL (O): 522168000; CROSS-REFERENCE (X): 264401000 264494000 264496000 522100000 522166000

**DT** - Corresponding document

CT - US3835003; US4139655; US4374751; US4394403; US4575330; US4694029; US5073643; US5387304; US5437964; US5639802; US5674922; US5721020; US5721289; US5783358; EP0732625; JP49-17040; JP50-151996; JP50-151997; JP50-158680; JP50-158698; JP52-30899; JP55-125105; JP56-8428; JP55-55420; JP56-149402; JP57-192429; JP60-247515; JP62-35966; JP62-101408; JP1-204915; JP1-213304; JP2-28261; JP2-75618; JP2-208305; JP3-160013; JP5-24119; JP6-228413; JP08085775; JP08-085775; JP08-208832; JP08-218296; JP08-269392; JP08-277385; JP10158385 Japanese Patent Abstract, vol. 014, No. 261 (c-0725), Mar. 15, 1990.

STG - (B1) U.S. Patent (no pre-grant pub.) after Jan. 2, 2001

AB - A photocurable resin composition suitable for photo-fabrication. The resin composition capable of being promptly cured by photo-irradiation, thereby reducing fabricating time and providing cured products having excellent mechanical strength and minimized shrinkage during curing to ensure high dimensional accuracy. The composition includes (A) an oxetane compound, (B) an epoxy compound, and (C) a cationic photo-initiator.

**UP** - 2002-15

1/1 LGST - ©EPO

PN - US6365644 B1 20020402 [US6365644]

**AP** - US39403199 19990913 [1999US-0394031]

ACT - 20031007 US/CC-A

CERTIFICATE OF CORRECTION

20040105 US/AS-A ASSIGNMENT

OWNER: DSM IP ASSETS B.V. HET OVERLOON 16411 TE HEERLEN;

EFFECTIVE DATE: 20031208

ASSIGNMENT OF ASSIGNORS INTEREST; ASSIGNOR: DSM

N.V. /AR;REEL/FRAME:014863/0133

20040713 US/RF-A

REISSUE APPLICATION FILED EFFECTIVE DATE: 20030926

**UP** - 2005-33

1/1 CRXX - ©CLAIMS/RRX

PN - 6,365,644 A 20020402 [US6365644]

PA - DSM N V NL; Japan Fine Coatings Co Ltd JP; JSR Corp JP

ACT - 20030926 REISSUE REQUESTED

ISSUE DATE OF O.G.: 20040713

REISSUE REQUEST NUMBER: 10/671438

**EXAMINATION GROUP RESPONSIBLE FOR REISSUEPROCESS: 1711** 

Reissue Patent Number:

20040105 REASSIGNED ASSIGNMENT OF ASSIGNORS INTEREST

Assignor: DSM N.V., DATE SIGNED: 12/08/2003

Assignee: DSM IP ASSETS B.V., HET OVERLOON 1, 6411 TE HEERLEN,

**NETHERLANDS** 

Reel 014863/Frame 0133

Contact: PILLSBURY WINTHROP LLP, PAUL L. SHARER,

INTELLECTUAL PROPERTY GROUP, P.O. BOX 10500, MCLEAN, VA

22102

Search statement 2

Query/Command: FILE INPADOC

- Time in minutes : 0,10 LGST The cost estimation below is based on Questel's standard price list Estimated cost : 0.13 USD Records displayed and billed : 1 0.70 USD Estimated cost : Cost estimated for the last database search : 0.83 USD 1.54 USD Estimated total session cost - Time in minutes: 0,11 CRXX The cost estimation below is based on Questel's standard price list Estimated cost : 0.21 USD Records displayed and billed : 1 Estimated cost : 6.00 USD Cost estimated for the last database search : 6.21 USD Estimated total session cost 7.75 USD - Time in minutes: 0,04 The cost estimation below is based on Questel's standard price list Estimated cost : 0.11 USD Cost estimated for the last database search : 0.11 USD 7.86 USD Estimated total session cost - Time in minutes : 0,56 PLUSPAT The cost estimation below is based on Questel's standard price list 1.63 USD Estimated cost : Records displayed and billed : 1.55 USD Estimated cost : Cost estimated for the last database search : 3.18 USD Estimated total session cost 11.04 USD Selected file: PLUSPAT PLUSPAT - (c) Questel-Orbit, All Rights Reserved. Comprehensive Worldwide Patents database Individual records for each Country or Patent Office Coverage: 77 patenting authorities; start dates vary from 1800 forward For PlusPat Fact Sheet, Pricing and FAQ, see the Questel.Orbit website Citations and FI/F-term classification available for Japanese documents

Search statement 2

Query/Command: FAM US6365644/PN

Last update of file: 2007/05/04 (YYYY/MM/DD) 2007-18/UP (last update)

1 Patent Groups

#### \*\* SS 2: Results 5

Search statement 3

#### **Query/Command: FAMSTATE NONSTOP**

#### 1/5 PLUSPAT - ©QUESTEL-ORBIT

PN - DE69706816 D1 20011025 [DE69706816]

STG - (D1) Granted EP number in bulletin

OTI - (D1) Photohärtbare Harzzusammensetzung zur Verwendung zum Photo-Herstellen dreidimensionaler Objekte

PA - (D1) JSR CORP (JP); JAPAN FINE COATINGS CO (JP); DSM NV (NL)

IN - (D1) WATANABE TSUYOSHI (JP); TAKEUCHI AKIRA (JP); UKACHI TAKASHI (JP); YAMAMURA TETSUYA (JP)

- (D1) G03C-009/08 G03F-007/038 G03F-007/075

PN2 - DE69706816 T2 20020425 [DE69706816]

STG2 - (T2) Trans. Of EP patent

OTI2 - (T2) Photohärtbare Harzzusammensetzung zur Verwendung zum Photo-Herstellen dreidimensionaler Objekte

PA2 - (T2) JSR CORP (JP); JAPAN FINE COATINGS CO (JP); DSM NV (NL)

IN2 - (T2) WATANABE TSUYOSHI (JP); TAKEUCHI AKIRA (JP); UKACHI TAKASHI (JP); YAMAMURA TETSUYA (JP)

IC2 - (T2) G03C-009/08 G03F-007/038 G03F-007/075

**AP** - DE69706816 19971212 [1997DE-6006816]

PR - JP35289396 19961213 [1996JP-0352893]

ICAA - G03C-009/08 [2006-01 A - I R M EP]; G03F-007/038 [2006-01 A - I R M EP]; G03F-007/075 [2006-01 A - I R M EP]

**ICCA** - G03C-009/00 [2006 C - I R M EP]; G03F-007/038 [2006 C - I R M EP]; G03F-007/075 [2006 C - I R M EP]

UP - 2001-43

#### 1/1 LEGALI - ©EPO

PN - DE69706816 D1 20011025 [DE69706816]DE69706816 T2 20020425 [DE69706816]

**AP** - DE69706816 19971212 [1997DE-6006816]

ACTE - 20040513 DE/8327-A CHANGE IN THE PERSON/NAME/ADDRESS OF THE PATENT OWNER OWNER: DSM IP ASSETS B.V., HEERLEN, NL

20040513 DE/8327-A

CHANGE IN THE PERSON/NAME/ADDRESS OF THE PATENT OWNER OWNER: JSR CORP., TOKIO/TOKYO, JP

20040513 DE/8327-A

CHANGE IN THE PERSON/NAME/ADDRESS OF THE PATENT OWNER OWNER: JAPAN FINE COATINGS CO., LTD., TOKIO/TOKYO, JP

**UP** - 2004-20

#### 2/5 PLUSPAT - ©QUESTEL-ORBIT

PN - EP0848294 A1 19980617 [EP-848294]

STG - (A1) Public. Of applic. With search report

TI - (A1) Photo-curable resin composition used for photo-fabrication of three-dimensional objects

 OTI - (A1) Photohärtbare Harzzusammensetzung zur Verwendung zum Photo-Herstellen dreidimentionaler Objekte
 (A1) Composition de résine photodurcissable utilisée pour la photofabrication d'objets en trois dimensions

PA - (A1) JAPAN SYNTHETIC RUBBER CO LTD (JP); JAPAN FINE COATINGS CO LTD (JP); DSM NV (NL)

IN - (A1) WATANABE TSUYOSHI (JP); TAKEUCHI AKIRA (JP); UKACHI TAKASHI (JP); YAMAMURA TETSUYA (JP)

IC - (A1) G03C-009/08 G03F-007/038 G03F-007/075

PN2 - EP0848294 B1 20010919 [EP-848294]

STG2 - (B1) Patent

T12 - (B1) Photo-curable resin composition used for photo-fabrication of three-dimensional objects

OTI2 - (B1) Photohärtbare Harzzusammensetzung zur Verwendung zum Photo-Herstellen dreidimensionaler Objekte (B1) Composition de résine photodurcissable utilisée pour la photofabrication d'objets en trois dimensions

PA2 - (B1) JAPAN SYNTHETIC RUBBER CO LTD (JP); JAPAN FINE COATINGS CO LTD (JP); DSM NV (NL)

IN2 - (B1) WATANABE TSUYOSHI (JP); TAKEUCHI AKIRA (JP); UKACHI TAKASHI (JP); YAMAMURA TETSUYA (JP)

IC2 - (B1) G03C-009/08 G03F-007/038 G03F-007/075

LA - ENGLISH (ENG)

**AP** - EP97203898 19971212 [1997EP-0203898]

PR - JP35289396 19961213 [1996JP-0352893] US98940797 19971212 [1997US-0989407]

ICAA - G03F-007/00 [2006-01 A - I R M EP]; G03F-007/038 [2006-01 A - I R M EP]; G03F-007/075 [2006-01 A - I R M EP]

ICCA - G03F-007/00 [2006 C - I R M EP]; G03F-007/038 [2006 C - I R M EP]; G03F-007/075 [2006 C - I R M EP]

EC - G03F-007/00S G03F-007/038 G03F-007/075F G03F-007/075M

DS - BE CH DE ES FI FR GB IT LI NL SE

DT - Basic

## 1/1 LEGALI - ©EPO

PN - EP0848294 A1 19980617 [EP-848294]EP0848294 B1 20010919 [EP-848294]

**AP** - EP97203898 19971212 [1997EP-0203898]

ACTE -19980617 EP/AK-A [+]

**DESIGNATED CONTRACTING STATES:** 

BE CH DE ES FI FR GB IT LI NL SE

19980617 EP/AX-A [+]

EXTENSION OF THE EUROPEAN PATENT TO

AL;LT;LV;MK;RO;SI

19981216 EP/17P-A [+]

REQUEST FOR EXAMINATION FILED

EFFECTIVE DATE: 19981019

19990303 EP/RBV-A [+]

DESIGNATED CONTRACTING STATES (CORRECTION):

BE CH DE ES FI FR GB IT LI NL SE

19990303 EP/AKX-A [+]

PAYMENT OF DESIGNATION FEES

BE CH DE ES FI FR GB IT LI NL SE

19990825 EP/17Q-A [+]

FIRST EXAMINATION REPORT

EFFECTIVE DATE: 19990713

20010919 EP/AK-A [+]

**DESIGNATED CONTRACTING STATES:** 

BE CH DE ES FI FR GB IT LI NL SE

20010928 EP/REG-A; CH/EP [+]

CH: ENTRY IN THE NATIONAL PHASE

<CH>

20011025 EP/REF-A

**CORRESPONDS TO:** 

(DE 69706816 20011025 [DE69706816])

20020101 EP/REG-A; GB/IF02 [+]

GB: EUROPEAN PATENT IN FORCE AS OF 2002-01-01

<GB>

20020215 EP/ET-A [+]

FR: TRANSLATION FILED

20020301 EP/NLV1-A [-]

NL: LAPSED OR ANNULED DUE TO FAILURE TO FULFILL THE

REQUIREMENTS OF ART. 29P AND 29M OF THE PATENTS ACT; NO

LEGAL EFFECT FROM THE DATE OF

20020717 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

<FI>

EFFECTIVE DATE: 20010919

20020731 EP/26-A [-] OPPOSITION FILED

OPPONENT: VANTICO AG; EFFECTIVE DATE: 20020529

20030226 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

<FI>

**EFFECTIVE DATE: 20010919** 

20030226 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

<NL>

EFFECTIVE DATE: 20010919

20030730 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

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EFFECTIVE DATE: 20010919

20030730 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

<NL>

EFFECTIVE DATE: 20010919

20030730 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

 $\langle SE \rangle$ 

**EFFECTIVE DATE: 20010919** 

20030910 EP/RAP2-A

PATENT OWNER REASSIGNMENT (CORRECTION)

OWNER: DSM IP ASSETS B.V.

20030910 EP/RAP2-A

PATENT OWNER REASSIGNMENT (CORRECTION)

OWNER: JAPAN SYNTHETIC RUBBER CO., LTD.

20030910 EP/RAP2-A

PATENT OWNER REASSIGNMENT (CORRECTION)

OWNER: JAPAN FINE COATINGS CO., LTD.

20040121 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

<BE>

**EFFECTIVE DATE: 20010919** 

20040121 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

<ES>

**EFFECTIVE DATE: 20020326** 

20040121 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

<FI>

**EFFECTIVE DATE: 20010919** 

20040121 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

<NL>

EFFECTIVE DATE: 20010919

20040121 EP/25-A [-]

LAPSED IN A CONTRACTING STATE

<SE>

EFFECTIVE DATE: 20010919

20041008 EP/REG-A; FR/TQ

FR: PARTIAL TRANSMISSION OF PROPERTY

<FR>

20070214 EP/R26-A [-]

OPPOSITION FILED (CORRECTION)

OPPONENT: HUNTSMAN ADVANCED MATERIALS (SWITZERLAND)

GMBH; EFFECTIVE DATE: 20020529

**UP** - 2007-07

3/5 PLUSPAT - @QUESTEL-ORBIT - image

PN - JP10168165 A 19980623 [JP10168165]

**STG** - (A) Doc. Laid open to publ. Inspec.

TI - (A) PHOTOCURABLE RESIN COMPOSITION FOR OPTICAL THREE-

DIMENSIONAL SHAPING

PA - (A) JSR CORP; NIPPON TOKUSHU COATING KK

PAO - (A) JSR CORP; NIPPON TOKUSHU COATING KK

IN - (A) YAMAMURA TETSUYA; WATANABE TAKESHI; TAKEUCHI AKIRA;

UKAJI TAKASHI

IC - (A) B29C-067/00 C08G-059/68 C08G-065/18 G03F-007/038

PN2 - JP3765896 B2 20060412 [JP3765896]

STG2 - (B2) Grant. Pat. With A from 2500000 on

IC2 - (B2) C08G-059/00 C08G-059/68 C08G-065/00 C08G-065/18 G03F-007/00

G03F-007/038 G03F-007/075

**AP** - JP35289396 19961213 [1996JP-0352893]

PR - JP35289396 19961213 [1996JP-0352893]

US98940797 19971212 [1997US-0989407]

ICAA - C08G-059/68 [2006-01 A F I B H JP]; C08G-065/18 [2006-01 A L I B H JP];

G03F-007/00 [2006-01 A - I R M EP]; G03F-007/038 [2006-01 A L I B H JP];

G03F-007/075 [2006-01 A - I R M EP]

ICCA - C08G-059/00 [2006 C F I B H JP]; C08G-065/00 [2006 C L I B H JP]; G03F-007/00 [2006 C - I R M EP]; G03F-007/038 [2006 C L I B H JP]; G03F-007/075 [2006 C - I R M EP]

FI - G03F7/038 503; B29C67/00; C08G65/18; C08G59/68

FTM - 2H025 AA00; 2H025 AA01; 2H025 AA03; 2H025 AA10; 2H025 AA11; 2H025 AA13; 2H025 AA18; 2H025 AB14; 2H025 AB20; 2H025 AC01; 2H025 AC08; 2H025 AD01; 2H025 BD03; 2H025 BD04; 2H025 BD20; 2H025 BD23; 2H025 CA25; 2H025 CA39; 2H025 CA48; 2H025 CC01; 2H025 DA11; 2H025 FA10; 2H025 FA39; 4F213 AA12.A; 4F213 AA44.A; 4F213 AB04; 4F213 WA25; 4F213 WB01; 4J005 AA07; 4J005 AA09; 4J036 AA01; 4J036 AJ08; 4J036 AJ10; 4J036 AK01; 4J036 AK02; 4J036 AK10; 4J036 AK11; 4J036 GA01; 4J036 GA20; 4J036 JA15

#### 4/5 PLUSPAT - @QUESTEL-ORBIT - image

PN - US6365644 B1 20020402 [US6365644]

STG - (B1) U.S. Patent (no pre-grant pub.) after Jan. 2, 2001

TI - (B1) Photo-curable resin composition used for photo-fabrication of three-dimensional object

PA - (B1) JSR CORP (JP); JAPAN FINE COATINGS CO LTD (JP); DSM NV (NL)

PA0 - DSM N.V., Heerlen [NL]

JSR Corporation, Tokyo [JP]

Japan Fine Coatings Company, Ltd., Tokyo [JP]

IN - (B1) WATANABE TSUYOSHI (JP); TAKEUCHI AKIRA (JP); UKACHI TAKASHI (JP); YAMAMURA TETSUYA (JP)

IC - (B1) C08F-002/46

**AP** - US39403199 19990913 [1999US-0394031]

PR - US39403199 19990913 [1999US-0394031] JP35289396 19961213 [1996JP-0352893] US98940797 19971212 [1997US-0989407]

ICAA - G03F-007/00 [2006-01 A - I R M EP]; G03F-007/038 [2006-01 A - I R M EP]; G03F-007/075 [2006-01 A - I R M EP]

ICCA - G03F-007/00 [2006 C - I R M EP]; G03F-007/038 [2006 C - I R M EP]; G03F-007/075 [2006 C - I R M EP]

EC - G03F-007/00S G03F-007/038 G03F-007/075F G03F-007/075M

PCL - ORIGINAL (O): 522168000; CROSS-REFERENCE (X): 264401000 264494000 264496000 522100000 522166000

**DT** - Corresponding document

**UP** - 2002-15

#### I/I LEGALI - ©EPO

PN - US6365644 B1 20020402 [US6365644]

**AP** - US39403199 19990913 [1999US-0394031]

ACTE - 20031007 US/CC-A

CERTIFICATE OF CORRECTION

20040105 US/AS-A

**ASSIGNMENT** 

OWNER: DSM IP ASSETS B.V. HET OVERLOON 16411 TE HEERLEN,;

**EFFECTIVE DATE: 20031208** 

ASSIGNMENT OF ASSIGNORS INTEREST; ASSIGNOR: DSM

N.V. /AR;REEL/FRAME:014863/0133

20040713 US/RF-A

REISSUE APPLICATION FILED

EFFECTIVE DATE: 20030926

**UP** - 2005-33

5/5 PLUSPAT - @QUESTEL-ORBIT - image

PN - US5981616 A 19991109 [US5981616]

STG - (A) United States patent

TI - (A) Photo-curable resin composition used for photo fabication of three-dimensional objects

PA - (A) JSR CORP (JP); JAPAN FINE COATINGS CO LTD (JP); DSM NV (NL)

PA0 - DSM N.V., Heerlen [NL]

JSR Corporation, Tokyo [JP]

Japan Fine Coatings Company, Ltd., Tokyo [JP]

IN - (A) WATANABE TSUYOSHI (JP); TAKEUCHI AKIRA (JP); UKACHI TAKASHI (JP); YAMAMURA TETSUYA (JP)

**IC** - (A) C08F-002/46

**AP** - US98940797 19971212 [1997US-0989407]

PR - US98940797 19971212 [1997US-0989407] JP35289396 19961213 [1996JP-0352893]

ICAA - G03F-007/00 [2006-01 A - I R M EP]; G03F-007/038 [2006-01 A - I R M EP]; G03F-007/075 [2006-01 A - I R M EP]

ICCA - G03F-007/00 [2006 C - I R M EP]; G03F-007/038 [2006 C - I R M EP]; G03F-007/075 [2006 C - I R M EP]

EC - G03F-007/00S G03F-007/038 G03F-007/075F G03F-007/075M

**PCL** - ORIGINAL (O): 522168000

**DT** - Corresponding document

1/1 LEGALI - ©EPO

PN - US5981616 A 19991109 [US5981616]

**AP** - US98940797 19971212 [1997US-0989407]

ACTE - 20040105 US/AS-A

ASSIGNMENT OWNER: DSM IP ASSETS B.V. HET OVERLOON 16411 TE HEERLEN,; EFFECTIVE DATE: 20031208 ASSIGNMENT OF ASSIGNORS INTEREST;ASSIGNOR:DSM N.V. /AR;REEL/FRAME:014863/0133

**UP** - 2005-33

Search statement 3

Session finished: 08 MAY 2007 Time 17:42:58

LEGALI - Time in minutes : 0,30

The cost estimation below is based on Questel's

standard price list

PLUSPAT - Time in minutes : 0,92

The cost estimation below is based on Questel's

standard price list

Estimated cost : 2.68 USD

Famstat displays

Estimated cost: 10.50 USD

1

Cost estimated for the last database search : 13.18 USD Estimated total session cost : 24.61 USD

Your session will be retained for 2 hours.

QUESTEL.ORBIT thanks you. Hope to hear from you again soon.

DATE: MAY 8, 2007 LIBRARY: PATENT FILE: ALL

Your search request is:

PATNO IS 6365644

Number of PATENTS found with your search request through: LEVEL  $1\dots$  1

Your search request has found 1 PATENT through Level 1. To DISPLAY this PATENT press either the KWIC, FULL, CITE or SEGMTS key. To MODIFY your search request, press the M key (for MODFY) and then the ENTER key.

For further explanation, press the H key (for HELP) and then the ENTER key.

#### LEVEL 1 - 1 PATENT

1. 6365644, April 2, 2002, Photo-curable resin composition used for photo-fabrication of three-dimensional object, Yamamura, Tetsuya - Ibaraki, Japan (JP); Watanabe, Tsuyoshi - Ibaraki, Japan (JP); Takeuchi, Akira - Ibaraki, Japan (JP); Ukachi, Takashi - Ibaraki, Japan (JP), 394031 (09), DSM N.V., Heerlen, Netherlands (NL), Foreign company or corporation (03) JSR Corporation, Tokyo, Japan (JP), Foreign company or corporation (03) Japan Fine Coatings Co., Ltd., Tokyo, Japan (JP), Foreign company or corporation (03), January 5, 2004 - ASSIGNMENT OF ASSIGNORS INTEREST (SEE DOCUMENT FOR DETAILS)., DSM IP ASSETS B.V. HET OVERLOON 16411 TE HEERLEN, (1), Reel and Frame Number: 014863/0133

CORE TERMS: compound, resin, composition, acrylate, meth, ether, cured, modified, atom, three-dimensional  $\dots$ 

#### LEVEL 1 - 1 OF 1 PATENT

#### UNITED STATES PATENT AND TRADEMARK OFFICE GRANTED PATENT

6365644

#### April 2, 2002

Photo-curable resin composition used for photo-fabrication of three-dimensional object

REISSUE: September 26, 2003 - Reissue Application filed Ex. Gp.: 1711; Re. S.N. 10/671,438 (O.G. July 13, 2004)

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APPL-NO: 394031 (09)

FILED-DATE: September 13, 1999

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CORE TERMS: compound, resin, composition, acrylate, meth, ether, cured,

modified, atom, three-dimensional ...

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